SHEET 1 OF 2

<b>FORM</b>	PTO-	1449

U.S. DEPARTMENT OF COMMERCE. PATENT AND TRADEMARK OFFICE

ATTY, DOCKET NO. MICRON,0950V2C1

APPLICATION NO. **Unknown** 

INFORMATION DISCLOSURE STATEMENT BY APPLICANT

APPLICANT

Agarwal, et al.

(USE SEVERAL SHEETS IF NECESSARY)

FILING DATE 10/6/2003 Herewith

		DATE	NAME	CLASS	SUBCLASS	FILING DATE (IF APPROPRIATE)
MINER	DOCUMENT NUMBER	DATE				
INITIAL	4,761,386	8/2/88	Buynoski			
	4,823,182	4/18/89	Okumura			
	4,884,123	11/28/89	Dixit, et al.		<del> </del>	
	4,895,770	1/23/90	Schintlmeister, et al.		<del> </del>	
	4,920,071	4/24/90	Thomas		-	
	5,225,771	7/6/93	Leedy		+	
	5,248,903	9/28/93	Heim		-	
	5,298,333	3/29/94	Maixner, et al.		<del></del>	
-	5,364,803	11/15/94	Lur, et al.		-	
	5,391,516	2/21/95	Wojnarowski, et al.			·
	5,441,904	8/15/95	Kim, et al.			
<del></del>	5,486,492	1/23/96	Yamamoto, et al.			
	5,506,499	4/9/96	Puar		_	
	5,541,427	7/30/96	Chappell, et al.		_	
	5,593,903	1/14/97	Beckenbaugh, et al.			
	5,668,394	9/16/97	Lur, et al.			
	5,684,304	11/4/97				
	5,693,377	12/2/97	Westmoreland, et al.		_	
	5,720,098	2/24/98			_	
	5,742,174	4/21/9				
	5,837,598	11/17/	98 Aronowitz, et al.			
	5,851,680	12/22/	98 Heau			
	5,920,081	7/6/99	Chen, et al.			
	5,962,867	10/5/9	9 Liu			
	5,968,594	10/19	/99 Hu, et al.			
-	5,994,716	11/30	/99 Ikeya, et al.			
	6,028,360	2/22/	00 Nakamura, et al.			

2005 DATE CONSIDERED

\*EXAMINER: INITIAL IF CITATION CONSIDERED, WHETHER OR NOT CITATION IS IN CONFORMANCE WITH MPEP 609; DRAW LINE THROUGH CITATION IF NOT IN CONFORMANCE AND NOT CONSIDERED, INCLUDE COPY OF THIS FORM WITH NEXT COMMUNICATION TO APPLICANT.

SHEET 2 OF 2

FORM PTO-1449  U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE  INFORMATION DISCLOSURE STATEMENT BY APPLICANT		E ATTY. DOCKET NO. MICRON.0950V2C1	APPLICATI (Unknown)		922			
		APPLICANT Agarwal, et al.						
(USE SEVERAL SHEETS IF NECESSARY)			FILING DATE Herewith 10/6/2003	GROUP 2823				
			U.S. PATENT DOCUMENTS					
CAMINER	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING ( (IF APPROI	)ATE PRIATE)	
INITIAL	6,017,818	1/25/00	Lu					
	6,069,482	5/30/00	Hilton				<del></del>	
	6,133,582	10/17/00	Osann, Jr., et al.					
(Ph)	6,200,649	3/13/01	Dearnaley					
-	111							
			FOREIGN PATENT DOCUMENTS			·		
		DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION		
EXAMINER,	1 1					YES	NO	
6	EP 0854 505 A2	7/22/98	Europe		ļ ·			
KIR						<del> </del>		
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EXAMINER		OTHER DOCU	MENTS (INCLUDING AUTHOR, TITLE, DATE, PERTI	NENT PAGES	6, ETC.)			
INITIAL (A)	IY-Ray Absorbtion Filit	Structure in	otoelectron/auger Electron Spectroscopy/Convestigation of TiBxNy Coatings". J. Vac.					
<del> </del>	Sade, et al., "Characte	erization of	FiB2/TiSi2 Bilayer Structure Deposited By	Sputtering"	, Mat. Res.			
	Vol. 402, pp. 131-136	, 1990						
$\vdash$	+							
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DATE CONSIDERED 3/2/2005

\*EXAMINER: INITIAL IF CITATION CONSIDERED, WHETHER OR NOT CITATION IS IN CONFORMANCE WITH MREP 608; DRAW LINE THROUGH CITATION IF NOT IN CONFORMANCE AND NOT CONSIDERED, INCLUDE COPY OF THIS FORM WITH NEXT COMMUNICATION TO APPLICANT.